

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Seung-Beom KIM, et al.

Serial No.: 10/776,546 Examiner: Nguyen, Tuan H.

Filed: February 10, 2004 Group Art Unit: 2813

Confirmation No.: 5443

For: METHOD OF FORMING A RELIABLE HIGH PERFORMANCE  
CAPACITOR USING AN ISOTROPIC ETCHING PROCESS

Mail Stop Issue Fee  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**APPLICANT'S COMMENTS ON EXAMINER'S STATEMENT OF REASONS FOR  
ALLOWANCE**

In the Examiner's Statement of Reasons for Allowance, the Examiner recited portions of the allowed independent claims and stated that the prior art failed to teach the recited portions. The applications note that it is a well known tenet of patent law that each allowed patent claim stands alone. Further, although the Examiner has indicated at least one reason for allowance, there are other reasons that claims are allowable. In other words, the Examiner has not recited all of the reasons for allowance, and there are reasons for allowability in addition to those given by the Examiner.

**Customer No. 20575**

Respectfully submitted,  
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